

| L Number | Hits | Search Text | DB | Time stamp |
|----------|------|--|--------------------------------|---------------------|
| 1 | 3873 | (wash\$3 or rins\$3 or clean\$3) same developing adj (liquid or solution or chemical) | USPAT; US-PGPUB; DERWENT | 2003/08/20 12:49 |
| 2 | 446 | (radiat\$3 or irradiat\$3 or expos\$3) same ultraviolet same (wash\$3 or rins\$3 or clean\$3) adj (liquid or solution or chemical or solvent) | USPAT; US-PGPUB; DERWENT | 2003/08/20 12:48 |
| 3 | 25 | ((wash\$3 or rins\$3 or clean\$3) same developing adj (liquid or solution or chemical)) and ((radiat\$3 or irradiat\$3 or expos\$3) same ultraviolet same (wash\$3 or rins\$3 or clean\$3) adj (liquid or solution or chemical or solvent)) | USPAT; US-PGPUB; DERWENT | 2003/08/20 13:05 |
| 4 | 1 | | USPAT | 2003/08/20 13:00 |
| 5 | 1 | | USPAT | 2003/08/20 13:01 |
| 6 | 1 | | USPAT | 2003/08/20 13:02 |
| 7 | 1 | | USPAT | 2003/08/20 13:02 |
| 8 | 1 | | USPAT | 2003/08/20 13:03 |
| 9 | 1 | | USPAT | 2003/08/20 13:03 |
| 10 | 131 | (wafer or substrate) same ((radiat\$3 or irradiat\$3 or expos\$3) same ultraviolet same (wash\$3 or rins\$3 or clean\$3) adj (liquid or solution or chemical or solvent)) | USPAT; US-PGPUB; DERWENT | 2003/08/20 13:06 |
| 11 | 110 | ((wafer or substrate) same ((radiat\$3 or irradiat\$3 or expos\$3) same ultraviolet same (wash\$3 or rins\$3 or clean\$3) adj (liquid or solution or chemical or solvent))) not (((wash\$3 or rins\$3 or clean\$3) same developing adj (liquid or solution or chemical)) and ((radiat\$3 or irradiat\$3 or expos\$3) same ultraviolet same (wash\$3 or rins\$3 or clean\$3) adj (liquid or solution or chemical or solvent))) | USPAT; US-PGPUB; DERWENT | 2003/08/20 13:07 |